

The Measurement of Thermal Stress in Plastic-Molded ICs by CCD Image Sensor

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In general, the IC is molded by epoxy resin. The molding process includes both heating and cooling processes. It has been reported that thermal stresses are generated in epoxy-molded ICs during these processes. The thermal stresses have adverse effects on IC function. For this reason, an analysis of thermal stresses in the epoxy-molded IC has been made. In this study, the photoelastic method was used for the analysis of thermal stresses. In the epoxy-molded IC, a CCD image sensor was used to take several images of the thermal stress, and the thermal stresses were then calculated with a personal computer.

1. Introduction

In general, the integrated circuit (referred to as the IC) is molded by epoxy resin. It has been reported that thermal stresses are generated in the epoxy-molded IC in the heating and cooling processes during molding, and converge at the interface between the IC chip and the epoxy resin molding.⁽¹⁾ As a result, the thermal stresses have adverse effects on the IC function. Therefore, an analysis of the thermal stresses in the epoxy-molded IC has been called for.

The purpose of this study is the measurement of the thermal stress using a com-